

Atomic Oxygen-Resistant, Static-Dissipative, Pinhole-Free Coatings for Spacecraft

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Motivation

- **Replacing metal satellite components with polymeric composites results in substantial weight savings**

BUT...

- **Polymeric composites are susceptible to erosion by atomic oxygen that is present in Low Earth Orbit (LEO)**
 - $10^{12} - 10^{16}$ O atoms/cm²-sec at 5 eV translational energy for a satellite moving at 8 km/sec
- **Most polymers are insulators, with the potential to accumulate significant static charge**

SOLUTION:

- **Apply a coating that is resistant to atomic oxygen (AO) and can dissipate static**

Degradation of Spacecraft Materials



S.K.R. Miller & B. Banks, *MRS Bulletin*, 35 (2010) 20-24.

Physical Sciences Inc.

VG10-109-3

- **Baseline: Kapton**

- Erodes at a rate of 3×10^{-24} cm³/incident O atom

Protective Coatings

- **PVD Aluminum**

- ✓ Surface is fully oxidized
- ✗ Has pinholes

- **PECVD SiO₂**

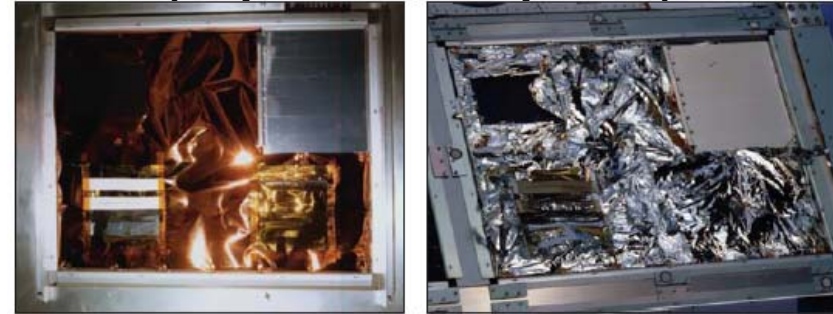
- ✓ Fully oxidized
- ✗ Has pinholes
- ✗ Insulator, builds static charge

- **Surface modification**

e.g., Photosil J. Kleiman, *MRS Bulletin*, 35 (2010) 55-65.

- ✗ Insulating surface

Al-backed Kapton Sheet (Kapton side exposed)

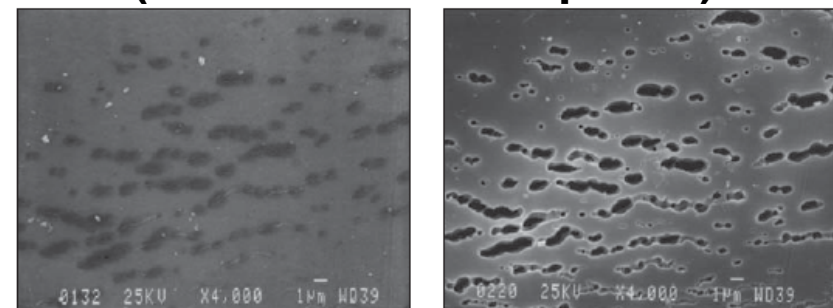


Before Flight

On-orbit

O'Neal et al., NASA SP-531 (1996).

Al-coated Kapton Sheet After Orbit (Aluminum side exposed)



Defects in Al

**Kapton remaining after
chemical removal of Al**

de Groh & Banks, J. Spacecr. Rockets 31 (1994), 656.

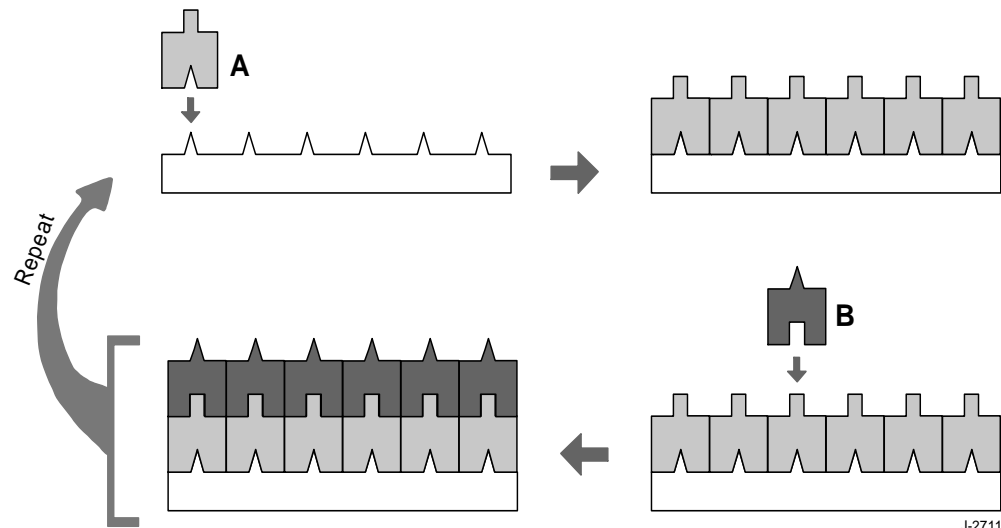
Requirements for Spacecraft Coatings

- **Resistant to atomic oxygen**
- **Static dissipative** Sheet resistance $< 10^5 \Omega/\text{square}$
- **UV-resistant**
- **Pinhole-free**
- **Thin** To reduce weight
- **Conformal** To protect areas out of line-of-sight
- **Optical properties requirements depend on application**
E.g., transparent for solar arrays, reflective for other uses
- **Mechanically robust** Adhesion, wear, stretch, bend, ...

⇒ *A new
deposition
method is
needed*
**ATOMIC
LAYER
DEPOSITION**

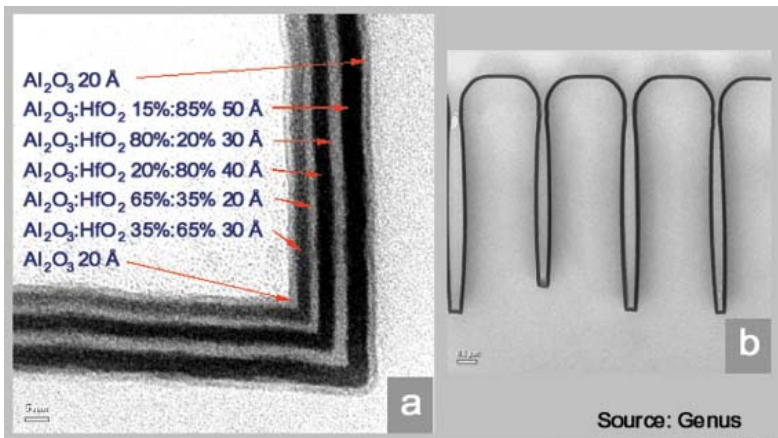
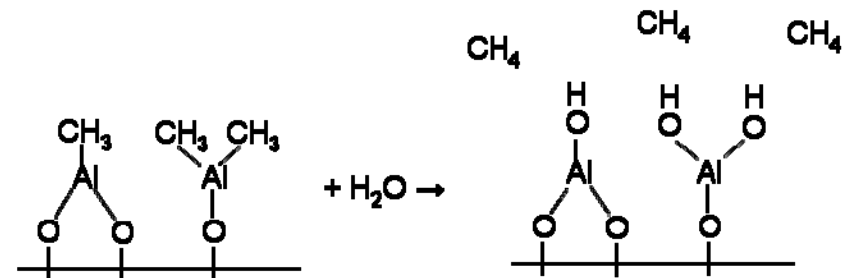
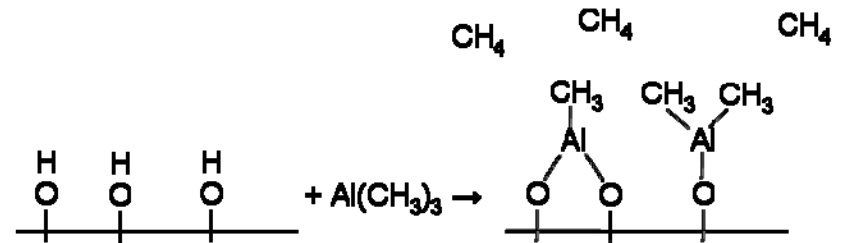
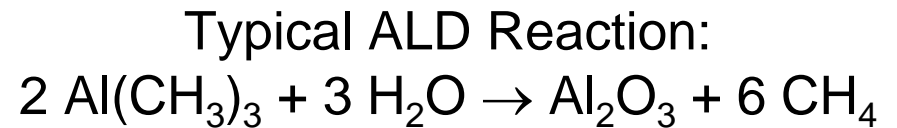
Atomic Layer Deposition (ALD)

- **Similar to Chemical Vapor Deposition (CVD)**
 - Thin film growth on a substrate from gas phase precursors
- **EXCEPT... precursors are delivered sequentially rather than simultaneously**
- **Purge in between \Rightarrow No gas phase reactions**
- **Self-limiting surface adsorption**
- **Monolayer-by-monolayer surface-mediated growth**
- **All exposed surfaces are coated**



Benefits of ALD

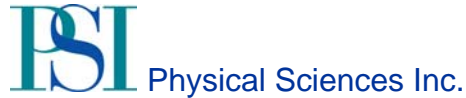
- **No pinholes**
- **Extremely conformal**
- **Extremely thin (nm)**
- **Low temperature process**
 - Can deposit on plastics
- **Commonly used in the semiconductor industry**



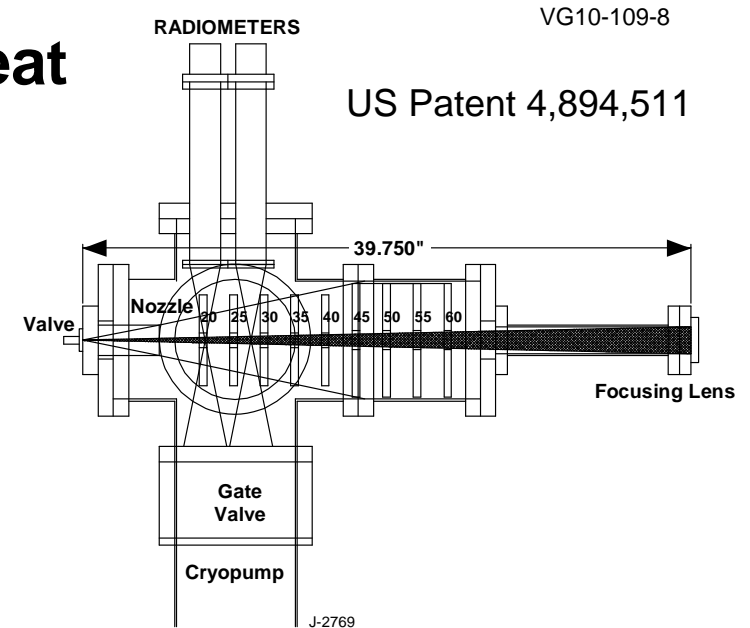
Screening Process for ALD-grown Spacecraft Coatings

- **Select a variety of oxide and other coatings to evaluate in simulated space conditions**
 - Some optically transparent, some reflective
- **Apply coatings to Kapton coupons with ALD**
 - Process temperatures $\leq 300^{\circ}\text{C}$
 - Coating thicknesses ranged from 6 – 100 nm
 - Both single layer and dual layer coatings
- **Expose to simulated Low Earth Orbit conditions in PSI's FAST™ AO source**
 - Over 60 samples with 10 different coatings have been evaluated
 - Uncoated Kapton used as control
- **Look for erosion (SEM), changes in conductivity, optical properties, etc.**

Atomic Oxygen Testing of Spacecraft Coatings: PSI FAST™ O Atom Source



- High power pulsed CO₂ laser to heat and dissociate O₂
- Closest approximation to LEO of any available O atom source
 - Energy distribution
Velocity and Boltzmann spread
 - Ion content
~1% O⁺, matches LEO at 600 km
 - UV/VUV photon flux
10⁻⁴ photons/O atom, matches LEO at 230 km
- Large beam area to test many samples
- Typical exposure: 10¹⁹ – 10²⁰ O atoms/cm² in 16 hours Equivalent to weeks to months on the International Space Station

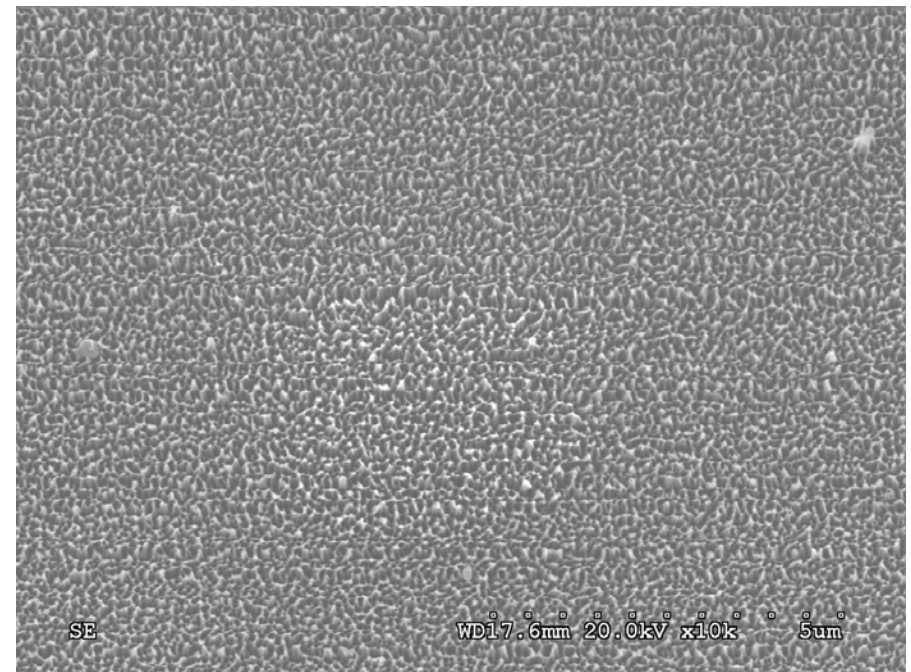
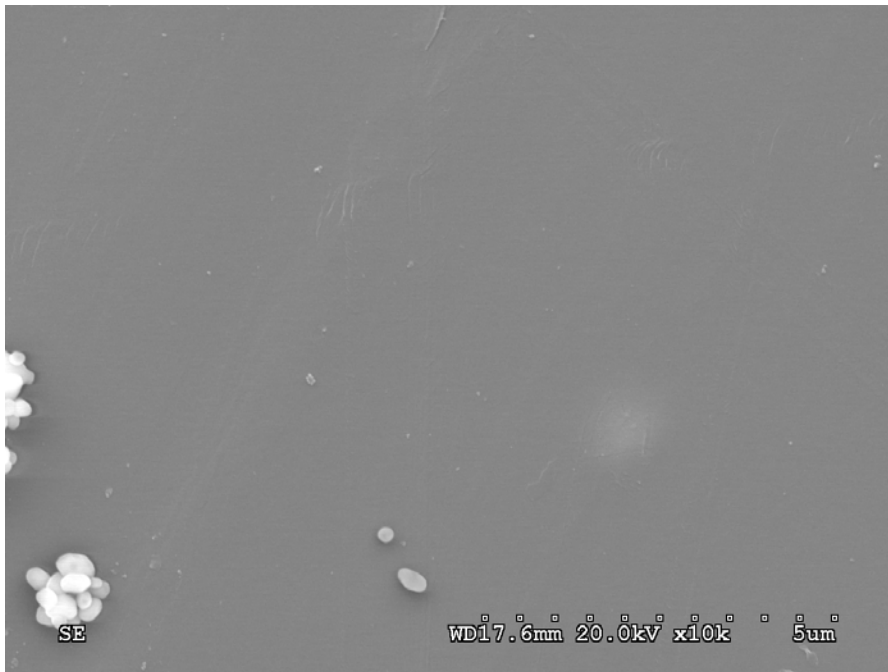


**Sample size
~1" x 1"**

Erosion of Kapton Control

Bare Kapton, As-Received

Bare Kapton, AO-Exposed

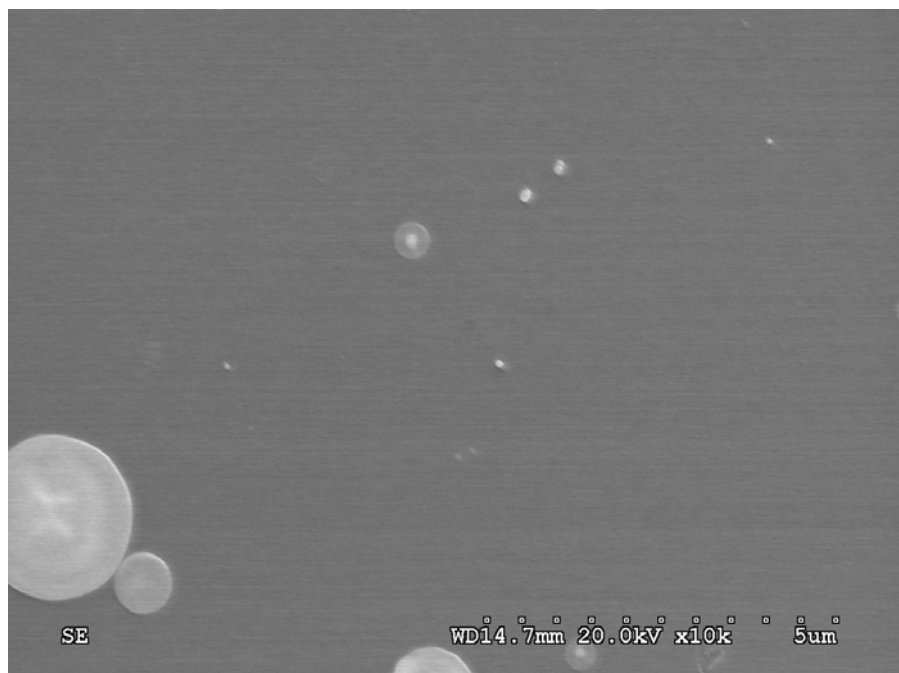


5 μ m

- **Bare Kapton is severely eroded by exposure to AO**
 - Dust particles are included in the “as-received” image to provide a focal point

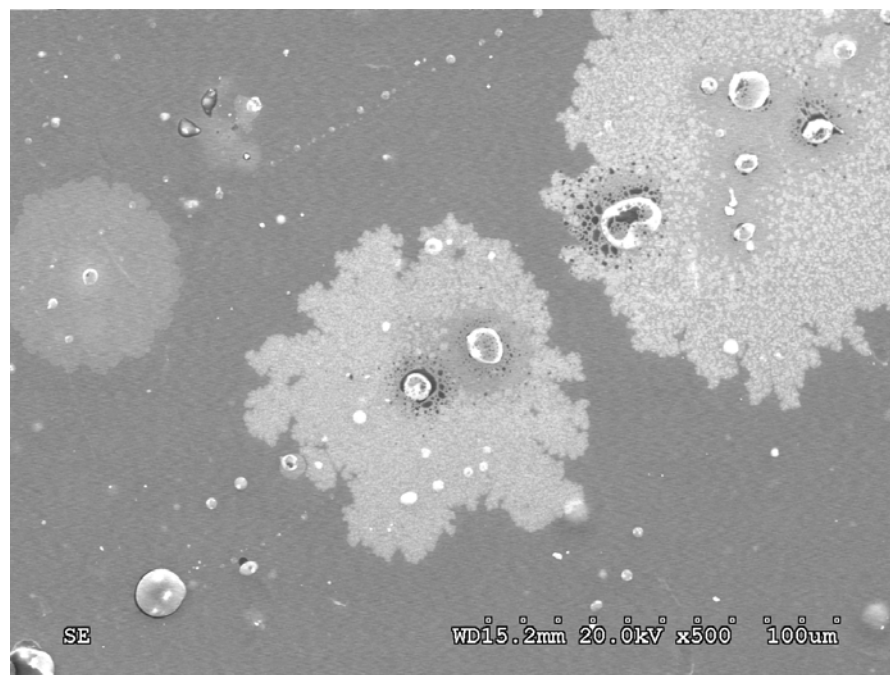
ALD Coatings Can Protect Kapton

Successful coating, after thermal cycling and AO exposure
Circles are contamination



5 μm

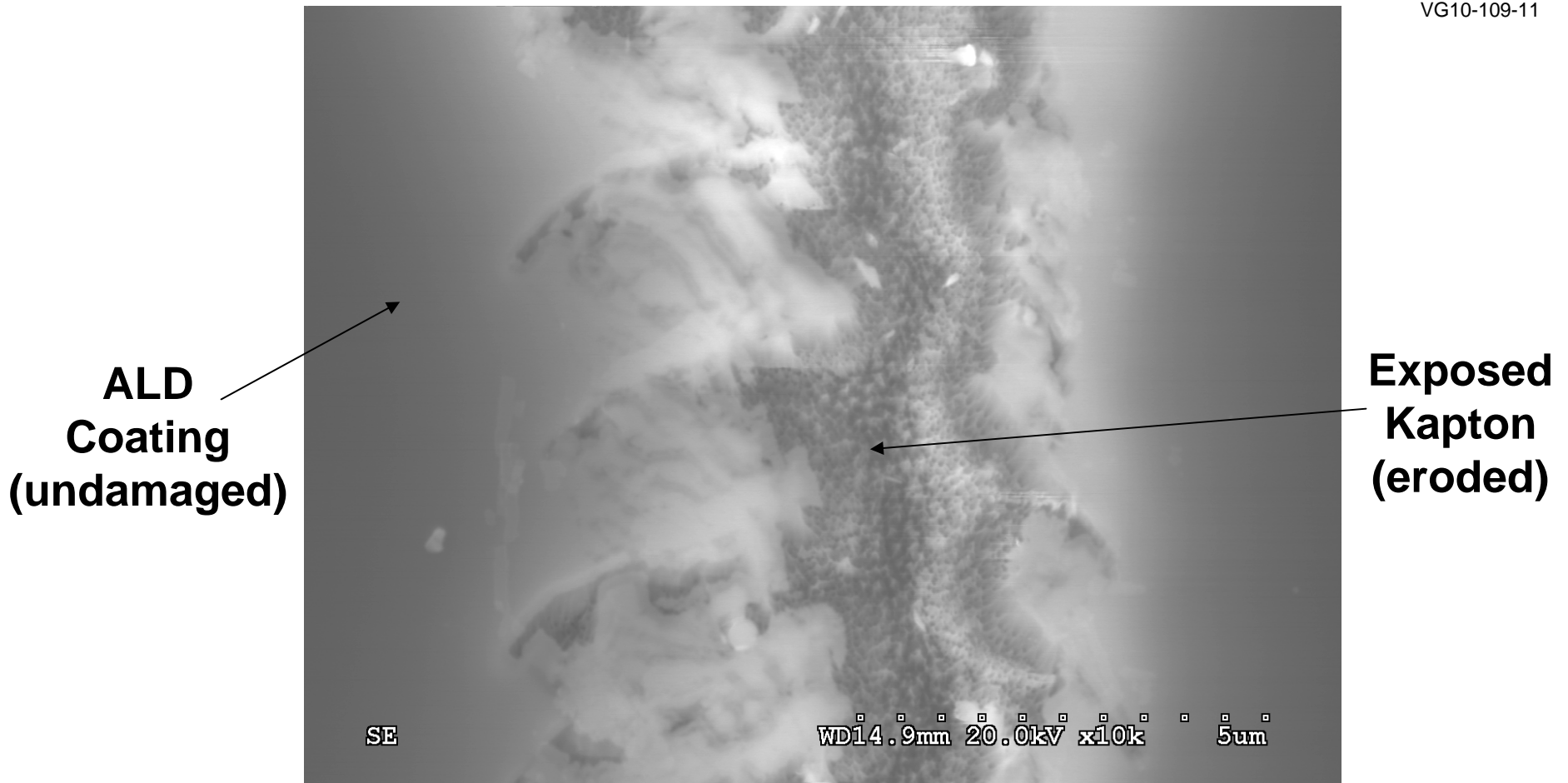
Unsuccessful coating, after AO exposure



100 μm

Erosion of Exposed Kapton Area on ALD-Coated Coupon

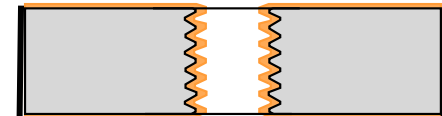
VG10-109-11



- ALD coating was scratched prior to AO exposure
- Erosion is limited to abraded area

Results of Screening Matrix

- **SEM:**
8 of 10 coatings showed no degradation after AO exposure.
- **Static Dissipation:**
6 of 10 coatings had sheet resistance $< 10^5 \Omega/\text{square}$ both before and after exposure to atomic oxygen.
- **Optical Properties:**
8 of 9 transparent coatings showed no change in UV-Vis reflectance. The reflective coating became more reflective.
- **Adhesion:**
Of 3 coatings tested, 2 passed a scribed tape adhesion test.
- **Conformality:**
The one coating tested demonstrated conductivity down a threaded hole

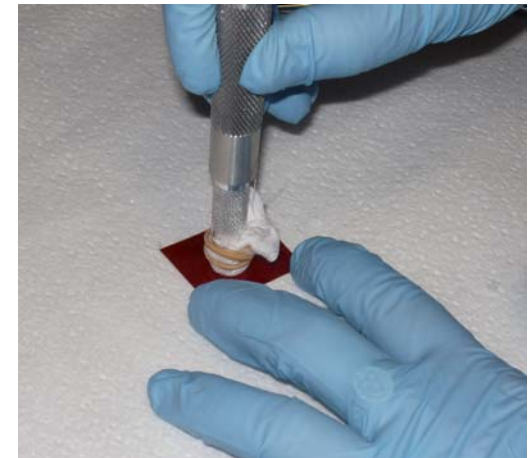
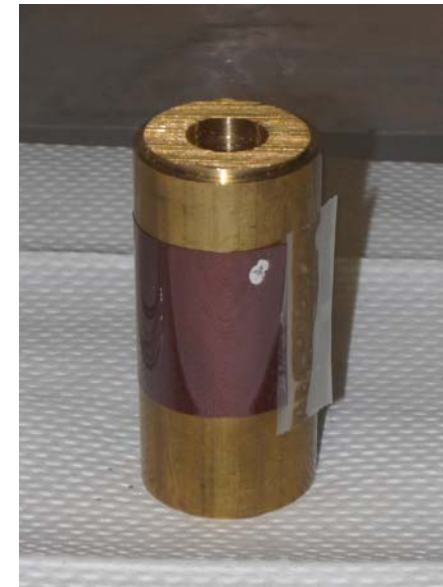


Down-Selection of ALD Coating

- **One single-layer transparent coating has been selected**
 - Focus on solar array applications
- **ALD process temperature reduced to 120°C**
 - A novel precursor has been synthesized
- **Minimum coating thickness determined to be 17 nm for Kapton substrate**
- **Further testing:**
 - Evaluate mechanical properties: Bend, stretch, wear, adhesion
 - Expose coatings to thermal cycles in vacuum
 - Demonstrate deposition on model spacecraft materials
 - Carbon-epoxy composite

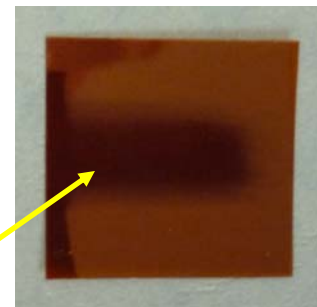
Evaluation of Mechanical & Thermal Properties

- **Coated Kapton coupons subjected to mechanical and thermal stresses**
 - **Stretch:** Apply tension in Instron mechanical test apparatus
 - **Bend:** Wrap around mandrel
 - **Wear:** Cheesecloth abrasion test
 - **Adhesion:** Scribed tape test
 - **Thermal Vacuum:** 5 cycles from -30°C to 70°C at 10^{-6} torr
- **Expose to AO after stretch, bend, wear, thermal vacuum**



Results of Mechanical & Thermal Testing

- **Coating passed 4-level scribed tape adhesion test**
- **Stretching, bending, and thermal cycling had no effect on the coatings**
 - No change in sheet resistance
 - No cracks or delaminations detected by SEM
 - No erosion after AO exposure
 - Fully coated coupons had mass losses < 0.3% of bare Kapton
 - Essentially inert within resolution of microbalance
- **Wear test removed the coating**
 - Mitigation: Apply sacrificial clean ablating coating in areas to be handled during satellite assembly

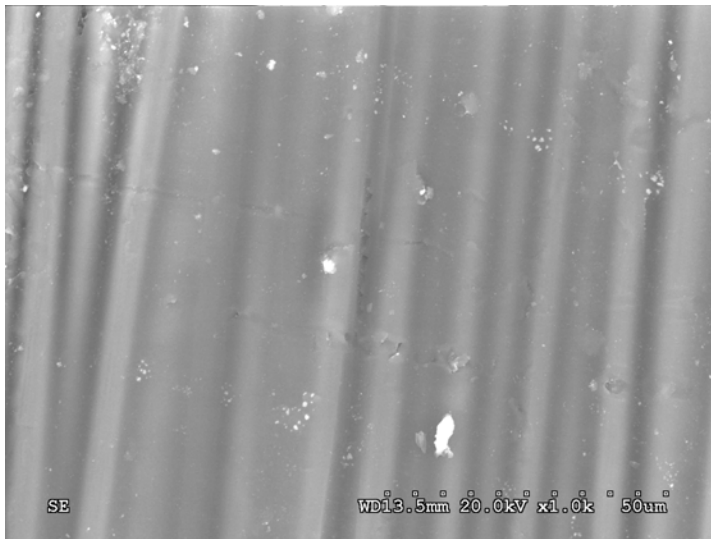


Worn region

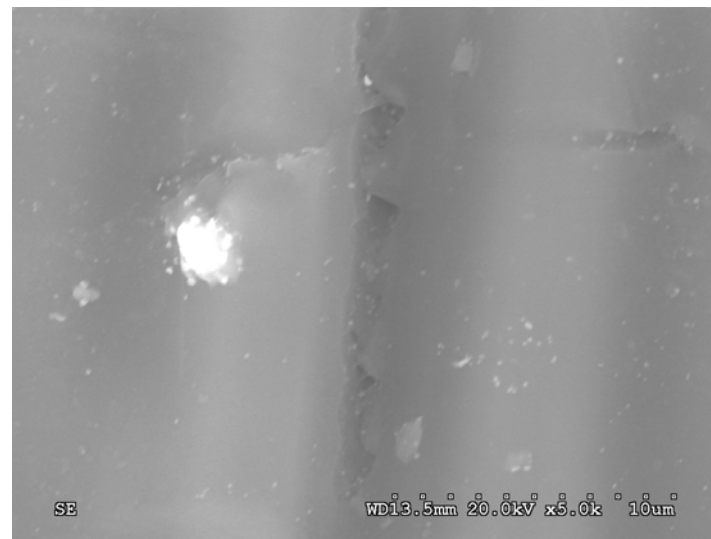
Protection of Carbon-Epoxy Composite: Bare Sample is Severely Eroded by AO

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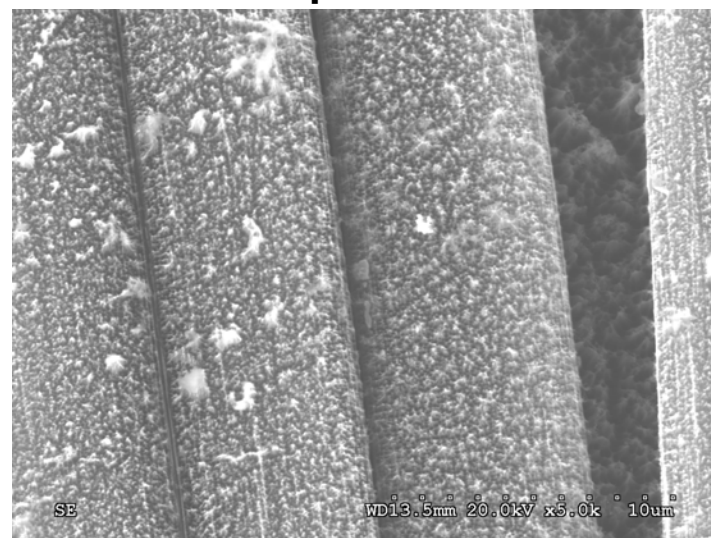
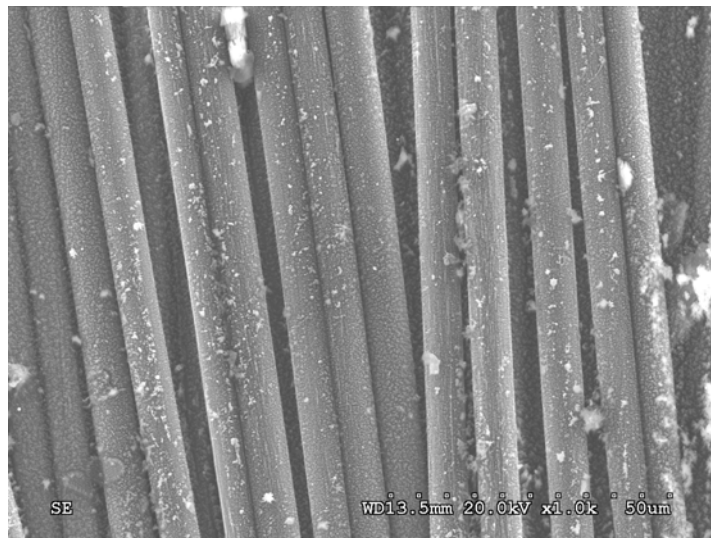
**As
Received:
C fibers
buried in
epoxy
matrix**



50 μm —————



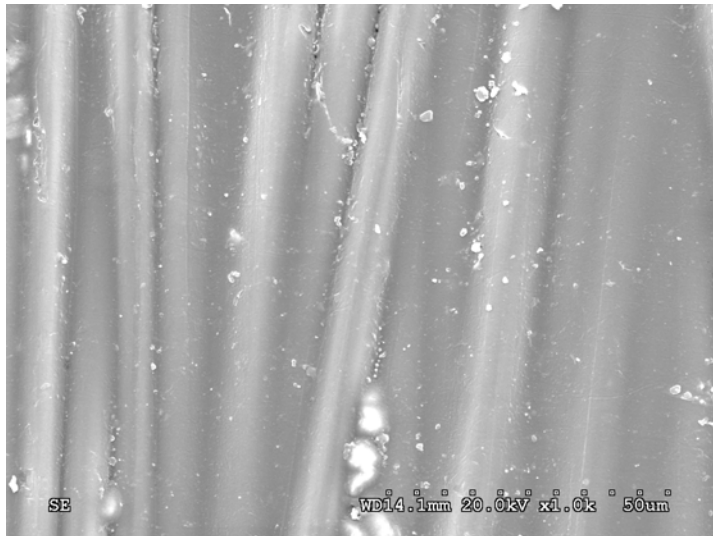
10 μm —————



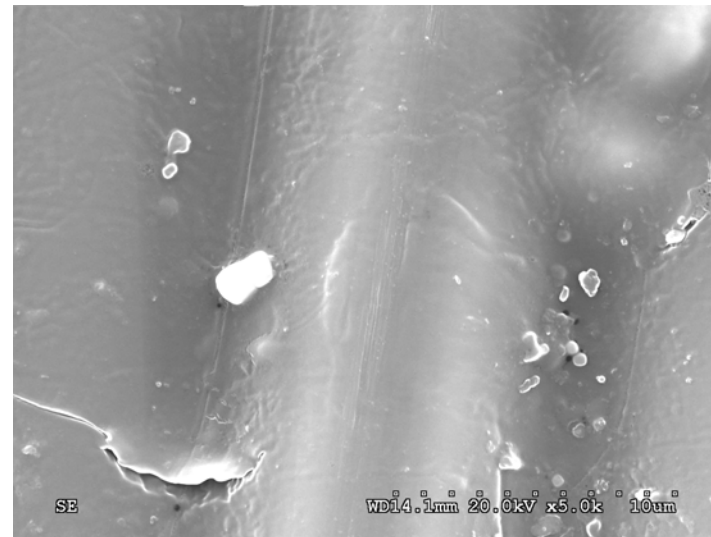
**After AO:
Epoxy
matrix is
gone,
fibers are
damaged**

Protection of Carbon-Epoxy Composite: ALD-Coated Sample is Unchanged

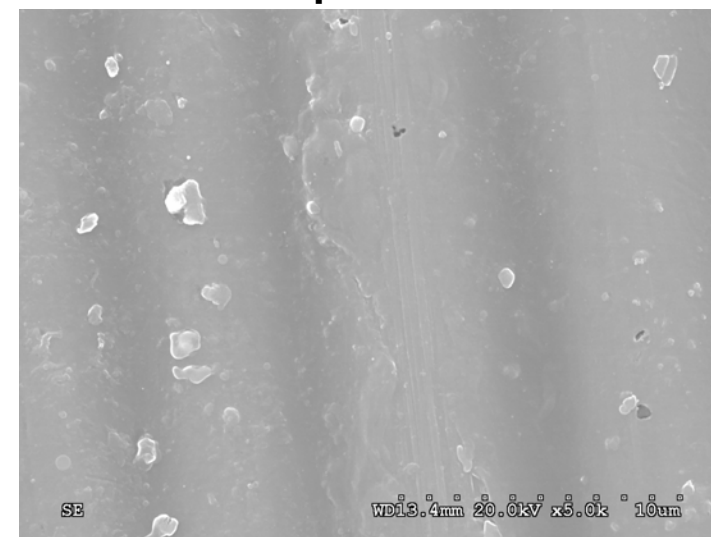
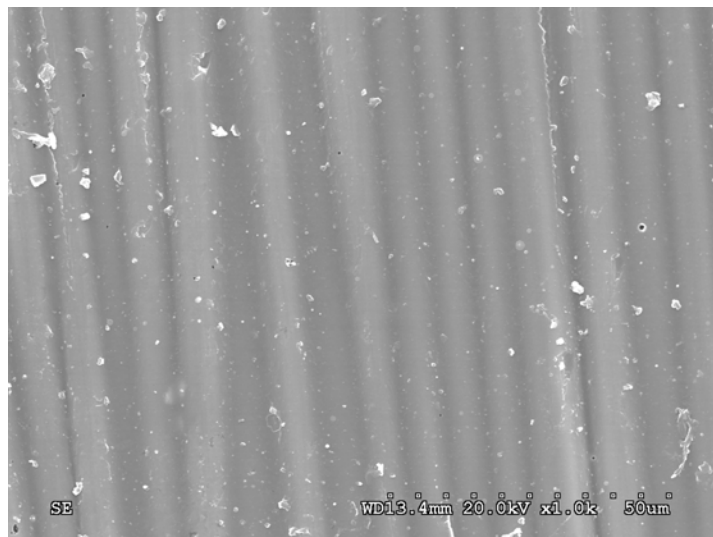
**After ALD
coating
is applied**



50 μm —————



10 μm —————



**After AO:
Matrix
and fibers
are intact.
No
damage
detected.**

Conclusions

- **We have developed a pinhole-free, static dissipative ultra-thin ALD-grown coating that protects polymeric and composite materials from erosion by atomic oxygen in a simulated Low Earth Orbit environment**
- **The minimum coating thickness to protect a Kapton substrate is 17 nm**
- **The coating survives bend, stretch and thermal stresses and exhibits good adhesion**
- **Current work: Scale up the process to coat model satellite components**

Supplemental Information

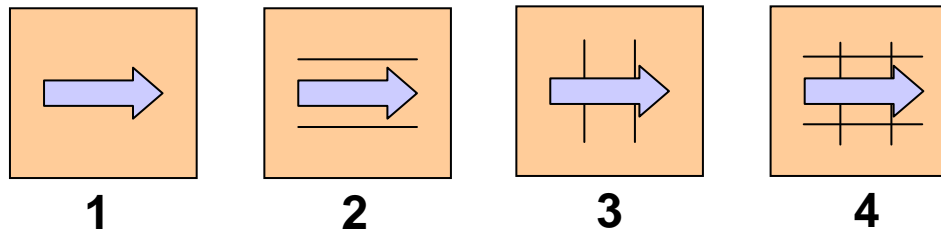
ISN'T ALD SLOW??

Yes, but....

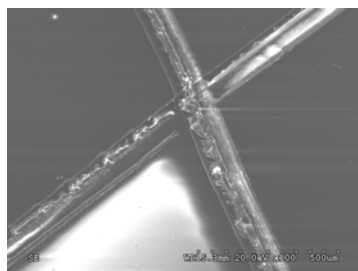
- **ALD can make coatings that can't be made by any other technique**
- **Lower deposition temperatures enables coating of polymeric materials**
 - Temperature uniformity requirements are less stringent than for CVD
- **ALD is well-suited to batch processing**
 - Non-line-of-sight
- **For thin coatings, the overall throughput may be comparable to PVD or PECVD processes**
 - Including sample loading, pump-down, etc.

Adhesion: Four Level Scribed Tape Test

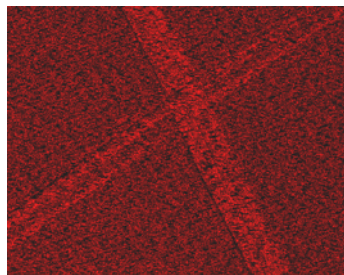
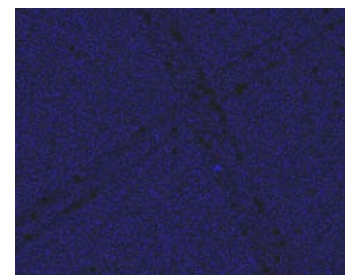
- Scratch the coating according to 4 patterns
- Apply Scotch tape and peel off quickly
- Look for delamination



Successful adhesion test of ALD coating



500 μm


Carbon (Kapton)

ALD Coating

Coating remains intact after 4th level tape test